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Patentanmeldung Nr. Patent application No. Demande de brevet nº

03405455.1

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Superhydrophobic coating

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Superhydrophobic Coating

The present invention relates to a composition capable of forming a superhydrophobic coating on a surface, a substrate having a superhydrophobic coating formed of such a composition, as well as to a method of production of such a superhydrophobic coating. Preferably the coatings are transparent.

Surfaces with particular wetting characteristics, i.e. water repellent surfaces, are widely used and of great interest to various industries, such as the textile industry, construction industry, e.g. corrosion or masonry protection, the automotive industry, in medical technologies as well as for sanitary products. Likewise, the use of surface modification techniques to impart such properties to surfaces of various substrates, natural or artificial, such as metal, glass, wood, ceramics, paper, polymers, fabrics, building materials, such as stone, concrete, marble, bricks, tiles, etc, to achieve the desired characteristics is a widely researched field.

The hydrophobicity of a material, i.e. its tendency to repel water, may be determined by the contact angle of a water droplet to the surface. In general, hydrophobicity is achieved by lowering the surface energy. Thus, non-hydrophobic materials may be rendered hydrophobic by applying a surface coating of low surface energy material. Chemically this may be done for example by incorporating apolar moieties, such as methyl or trifluoromethyl groups, into the surface. Superhydrophobic properties, typically referring to contact angles larger than about 150° and theoretically up to 180°, additionally require a high surface roughness. On a rough and hydrophobic surface air can be trapped underneath the water droplet which greatly reduces the actual liquid/solid contact area and thus the contact angle increases. With higher contact angles, e.g. contact angles of more than about 150°, other important effects like self-cleaning properties or enhanced water sliding behaviour can be obtained (Yoshimitsu, Z. et al, Langmuir 18, 5818 (2002)). Yet, if the surface roughness is too high and reaches the submicrometer scale light is scattered at the surface and the coating appears no longer transparent. Thus, to obtain optically neutral coatings the roughness has to be restricted to be well below the wavelength of visible light.

Many techniques of rendering surfaces superhydrophobic are described in the literature (Nakajima, A. et al, Monatsh. Chem. 132, 31 (2002); L. Feng et al., Adv. Mater. 14, 1857 (2002)). Most common are plasma polymerization or etching of apolar polymers like

polypropylene or polytetrafluoroethylene, plasma enhanced chemical vapor deposition of methyl or fluorine containing silanes, solidification of molten polymers or waxes, sublimation material and paint or sprays containing hydrophobized microbeads or evaporation of volatile compounds (Miwa, M. et al, Langmuir 16, 5754 (2000)). In order to increase the roughness very often additional steps like mechanical treatment, chemical or plasma etching or anodic oxidation are necessary before or after the coating step. However, there are several disadvantages associated with these methods, such as complicated and thus time-consuming procedures, expensive starting materials like fluorinated silanes and/or extreme reaction conditions which restrict the applicability to few resistant materials. In addition only a few coatings are optically transparent.

Thus, having regard to the wide variety of materials in daily life where a transparent and water repellent coating is highly desirable there is clearly a need for superhydrophobic, transparent surfaces as well as to simple and economical methods of preparation of such surfaces, which are overcoming the disadvantages mentioned hereinabove.

It is therefore an object of the present invention to provide a composition capable of forming a superhydrophobic coating on a surface, which is characterized by having contact angles of higher than about 140°, preferably higher than 150° and more preferably higher than 160°.

It is another object of the present invention to provide a substrate having a superhydrophobic coating formed of such a composition. The substrates treated with such surface coatings have a higher hydrophobicity, and thus show water repellent properties as well as excellent durability and smear resistance. In addition the superhydrophobic coatings of the invention are optically transparent.

It is yet a further object of the present invention to provide a method of production of such superhydrophobic coatings formed by the compositions of the invention, which is characterized by its simplicity, efficacy and low cost.

O

The use of silanes as surface coatings is known in the art. However, silanization with silanes such as trichloromethylsilane (TCMS) or (3-phenypropyl)-methyldichlorosilane (PMDS) in the gas phase yields contact angles of 95° or around 60°, respectively, which clearly are lying outside the desired superhydrophobic range.

Applicants have now surprisingly discovered that silanization with a composition comprising at least one compound of formula I and at least one compound of formula II

$$R^{a}Si(R^{1})_{n}(X^{1})_{3-n}$$
 I $R^{b}Si(R^{2})_{m}(X^{2})_{3-m}$ II

wherein

R^a is a straight-chain or branched C₍₁₋₂₄₎ alkyl group,

R^b is an aromatic group which is linked by a single covalent bond or a spacer unit to the Si- atom,

R¹ and R² are independently of each other a lower alkyl group,

X1 and X2 are independently of each other a hydrolysable group, and

n, m are independently of each other 0 or 1,

with the proviso that if n and m are independently of each other 0 or 1, X may represent the same or different groups,

yields a polysiloxane coating with superhydrophobic properties, i.e. having contact angles in the superhydrophobic range, preferably yielding contact angles of higher than about 140° , preferably higher than 150° and more preferably higher than 160° . Furthermore these coatings have been shown to have sliding angles lower than 20° for a $10~\mu l$ water droplet and are optically transparent.

It is understood that the term "straight-chain or branched $C_{(1-24)}$ alkyl group" includes preferably straight chain and branched hydrocarbon radicals having 1 to 16, more preferably 1 to 12, more preferably 1 to 8 carbon atoms and most preferred 1 to 4 carbon atoms, such as methyl, ethyl, n-propyl, isopropyl, n-butyl and isobutyl groups.

It is understood that the term "aromatic" includes optionally substituted carbocyclic and heterocyclic groups comprising five-, six-or ten-membered ring systems, such as furane, phenyl, pyridine, pyrimidine, or naphthalene, preferably phenyl, which are unsubstituted or substituted by an optionally substituted lower alkyl group, such as methyl, ethyl or trifluoromethyl, a halogen, such as fluoro, chloro, bromo, preferably chloro, a cyano or nitro group

It is understood that the term "spacer unit" includes a straight-chain or branched alkyl residue, having 1 to 8 carbon atoms, preferably 1 to 6, more preferably 1, 2 or 3 carbon atoms.

It is understood that the term "lower alkyl" includes straight chain and branched hydrocarbon radicals having 1 to 6 carbon atoms, preferably 1 to 3 carbon atoms. Methyl, ethyl, propyl and isopropyl groups are especially preferred.

It is understood that the term "hydrolysable group" includes a halogen, such as fluoro or chloro, preferably chloro, or an alkoxy group, such as a straight chain and branched hydrocarbonoxy radical having 1 to 6 carbon atoms, preferably 1 to 3 carbon atoms, wherein methoxy, ethoxy, propoxy and isopropoxy groups are especially preferred.

Particularly preferred examples of compounds of formula I include trichloromethylsilane (TCMS), trichloroethylsilane, trichloro(n-propyl)silane, trimethoxymethylsilane and triethoxymethylsilane and particularly preferred examples of compounds of formula II include (3-phenylpropyl)-methyldichlorosilane (PMDS), benzyltrichlorosilane, methylbenzyltrichlorosilane and trifluoromethylbenzyltrichlorosilane.

In case of acid-sensitive substrates it is preferred to use alkoxysilanes, such as methyltriethoxysilane, (3-phenylpropyl)-methyldimethoxysilane or (3-phenylpropyl)-methyldiethoxysilane, to avoid the formation of hydrochloric acid during hydrolysis of the silanes with water molecules in the reaction volume or at the substrate surface.

The volume ratio of compound of formula I to compound of formula II ranges from 1:100 to 100:1, preferably from 1:50 to 50:1, more preferably from 1:10 to 10:1, most preferably from 1:1 to 5:1 depending on the nature of the compounds and the nature of the substrate. For example, on glass slides the highest contact angles of up to 165° were observed with a composition comprising TCMS and PMDS in a volume ratio of 3:1.

The compositions of the present invention may be applied to a substrate of choice in a coating reaction, which is an atmospheric pressure chemical vapour deposition without carrier gas comprising the following steps:

In a first step the substrate surface is cleaned from particles and any adsorbed impurities, such as by ultrasonication in water and in an apolar solvent usually. For example, glass substrates may be cleaned by ultrasonication in a mixture of hydrochloric acid and methanol and afterwards in trichloromethane. This step is followed by an optional activation step to create functional groups, such as hydroxyl groups and the like, in sufficient frequency at the surface to allow condensation reaction with the silanes to occur and to ensure a proper adhesion of the coating. Good activation results for all materials have been observed for example using a high frequency plasma treatment in a low pressure oxygen, nitrogen or hydrogen atmosphere.

In case of glass or other resistant materials a piranha-solution (sulphuric acid: hydrogen peroxide, 2:1) can be used alternatively. For materials having a sufficient amount of functional groups present at the surface, such as hydroxyl groups and the like, such as cellulose, e.g. cotton or wood, the activation step can be omitted.

A simple desiccator may be used as reaction vessel for the silanization. The desiccator is flushed by a suiteable carrier gas, e.g. a nitrogen/water gas mixture. Two separate flasks with the two silanes are placed into the desiccator and the substrate is added on a special holder or scaffold. The desiccator is closed and the reaction can be carried out unattended at temperatures ranging from 0 to 100 °C, preferably at room temperature. Depending on the volatility of the silanes, the reaction may be run at atmospheric pressure or lower pressures if necessary. The reaction is completed within 0 to 24 hours and typically after twelve hours. After rinsing with any aqueous solvent, such as water, the coated substrate is ready for use.

As a final step the coated substrate may optionally be submitted to a curing step to complete the condensation reaction of remaining free hydroxyl groups at the surface and inside the layer, thereby further increasing the stability of the silane layer by forming additional cross-linking Si-O-Si bonds within the layer or from the substrate to the layer.

Alternatively, silanization may be achieved in solution, wherein a cleaned and optionally activated substrate is placed at room temperature under stirring in a previously prepared solution comprising the two silanes dissolved or suspended in an aprotic solvent, such as toluene. After 3 to 4 hours the substrate is removed, rinsed with for example ethanol and subsequently water and dried.

With small adaptations to mainly the cleaning and activation steps, which are obvious to a person skilled in the art, the coating reaction is also applicable to other materials.

The substrates of interest for the present invention may include a wide range of materials, natural or artificial, e.g. metal, glass, ceramics, paper, wood, polymers, fabrics, cellulose and its derivatives, biodegradable materials, construction and building materials, such as stone, concrete, marble, bricks, tiles, and other inorganic or organic materials and can be porous or non-porous, moulded or shaped, rigid or flexible, in various shapes and forms, e.g. in form of films, powders, granules, particles, woven and non-woven layers, webs, tapes, panes, pipes and the like. Representative substrates comprising such materials may include textiles, glass devices such as glass panes, mirrors, etc., sanitary products, cars, etc.

Characterization of the surface coatings of the invention by scanning electron microscopy and scanning force microscopy demonstrated the formation of distinct geometrical forms, such as thin filaments giving rise to the required surface roughness (Figure 1-3). The fibers ranged from very short, nearly spherical bases up to several μm in length with more uniformly distributed diameters ranging from approximately 20 nm to 160 nm. AFM and X-ray reflectivity measurements revealed a mean layer thickness of 7nm to 10nm. The root-mean-square roughness as determined by scanning force microscopy from different samples ranged from 20nm to 30nm. The observed surface roughness may be further increased depending on the nature of the substrate to be coated: for example, the micro-roughness of a sandblasted glass surface may add to the nano-roughness of the coating mimicking the surface structure found on hydrophobic plant leaves. In these cases, contact angles above 160° as well as hardly measurable sliding angles of 2° were observed with a 10 μ l water droplet.

Such unexpected formation of the surface roughness during condensation reaction as a consequence of self-organisation of the silanes of the present invention is a great advantage over many other coating methods, since the main prerequisites of superhydrophobicity, namely roughness and low surface energy, are addressed in one single step.

It was further shown that the coatings of the invention were transparent (Figure 4) and possessed high durability. No changes in contact angles were observed e.g. after heat treatment at 250 °C for 24 h or dipping a coated glass slide into liquid nitrogen for several minutes as well as irradiation with UV-light for 5 hours at 35 mW/cm² (Figure 5) Furthermore the coating is inert to water vapour (Figure 6) and several organic solvents such as ethanol, acetone or trichloromethane.

The following non-limiting Examples are illustrative for the present invention.

Legend to the figures

- Fig. 1. SEM image of the MPPS coating on a silicon wafer (3.5 μ m by 2.7 μ m). The filaments are up to 1 μ m long and about 40 nm in diameter.
- Fig. 2. 3D-presentation of an AFM height image of a MPPS-coated glass slide. The z-scale of 130 nm denotes the height difference from lowest to highest pixel.
- Fig. 3. X-ray reflectivity curve of a MPPS-coated glass slide.
- Fig. 4. UV-Vis spectra of a MPPS-coated glass slide compared to a purified glass slide.
- Fig. 5. Durability of a MPPS-coated glass slide subjected to long-term UV-irradiation.
- Fig. 6. Durability of a MPPS-coated glass slide subjected water vapour.
- Fig. 7. A 10 μl water droplet on a coated cotton fabric.
- Fig. 8. A 10 μl water droplet on a wood.

EXAMPLES

Materials. Microsope glass slides purchased from Menzel, Braunschweig, Germany (26 mm by 76 mm, thickness 0.13 – 0.16 mm) and polished silicon wafers purchased from CrysTec, Berlin (15 mm by 15 mm) were used for contact angle measurements and AFM imaging. Silicon cantilever chips were used as silicon substrate for the electron microscopy samples. TCMS, PMDS and other silanes were purchased from ABCR, Germany, and used without further purification.

Cleaning. Glass slides were ultrasonicated for 30 min in a 1:1 mixture of conc. HCl/methanol, rinsed with bidest. water and dried under a nitrogen flow. Afterwards they were ultrasonicated in trichloromethane for 30 min and again rinsed with bidest. water and dried under a nitrogen flow.

Activation. A laboratory plasma machine "Femto" from Diener electronic, Nagold, Germany, is used for high frequency plasma activation. Best activation results were obtained by low pressure high frequency plasma treatment in an oxygen atmosphere. Alternatively treatment in hot piranha-solution (conc. H₂SO₄/H₂O₂ in the ratio 2:1) for 20 min can be used for glass substrates.

Characterization methods. Contact angle and sliding angle measurements were performed with the Contact Angle System OCA and included software from Dataphysics, Stuttgart, Germany. The sample was kept at $25\pm1^{\circ}$ in a constant-temperature chamber. Both contact angle and sliding angle of a particular droplet were measured at the same position on the sample. Characterization of the surface quality was performed with a 10 μ l water droplet.

Scanning force microscopy was performed with a PicoSPM scan head (Molecular Imaging, Phoenix, Arizona) controlled by a RHK SPM1000 electronics and SPM32 software (RHK Technology Inc., Troy, Michigan). All measurements were performed in intermittent contact mode with silicon cantilevers. Measurements in cyclooctane were performed in the standard liquid cell from Molecular Imaging.

X-ray reflectivity measurements were performed with a Siemens D-500 powder diffractometer using CuK_{α} radiation ($\lambda = 1.5406 \text{Å}$).

For electron microscopy investigations glass samples were sputtered with Au (< 10 nm) and measured on a Jeol 25-S microscope. Silicon samples were sputtered with C (3nm or 8 nm)

and measured on a Philips CM12 microscope. All images were acquired using a secondary electron detector.

Electrostatic charging. MPPS-coated glass slides can be charged electrostatically. Simple rubbing with dry fingers is enough to charge the slide. After charging the placement of a water drop onto the sample is impossible. The drop is immediately accelerated off the glass slide. Further investigations on this effect are in progress.

Example 1

MPPS coating obtained by silanization of a glass slide with a total area of approximately 200 cm² with a mixture of TCMS and PMDS in a ratio of 3:1 in an atmospheric pressure chemical vapour deposition without carrier gas:

Prior to the silanization reaction the glass slide was cleaned from particles and any adsorbed impurities by ultrasonication in a mixture of hydrochloric acid and methanol (ratio 1:1) and afterwards in trichloromethane, followed by activation of the surface by treatment with a Piranha-solution (conc. H₂SO₄/H₂O₂ in the ratio 2:1) for 30 min at 90°C. Subsequently the glass slide was rinsed with purified water and dried with nitrogen gas. The silanization was carried out in a simple desiccator as reaction vessel flushed by a nitrogen/water gas mixture. Two separate flasks with the two silanes were placed into the desiccator and the glass substrates were added on a scaffold. The desiccator was closed and the reaction was carried out at room temperature for 12 hours. After rinsing with water the coated glass substrates are ready for use.

Contact angles and sliding angles of a water drop were measured as indicated above and are shown in Table 1.

The root-mean-square roughness R_{RMS} and mean layer thickness were determined by atomic force microscopy and X-ray reflectometry. In case of an MPPS-coated glass sample a root-mean-square roughness R_{RMS} of 27 nm and a mean layer thickness of $10(\pm 1)$ nm (determined by AFM) and 7.5(± 1) nm (determined by X-ray reflectometry) were observed

Examples 2-7

Silanizations were performed as described under Example 1. Contact angles and sliding angles were measured as indicated above and are shown in Table 1.

Example	Compound of	Compound of	Ratio	Contact	Sliding
No	formula I	formula II	A:B	angle	angle
2	Methyltrichlorosilan	(3-Phenylpropyl)- methyldichlorosilan	3:1	175°	13°- 2° *
3	Methyltrichlorosilan	Benzyltrichlorosilan	3:1	155,2°± 2,1°	21,5°± 2,5°
4	Methyltrimethoxysilan	(3-Phenylpropyl)- methyldichlorosilan	3:1	168° ± 4.8°	13,2°± 1,3°
5	Methyltriethoxysilan	(3-Phenylpropyl)- methyldichlorosilan	3:1	149.5°± 2.9°	18,2°± 0,8°
5	Ethyltrichlorosilan	(3-Phenylpropyl)- methyldichlorosilan	3:1	164.6°± 3.4°	8,0°± 1,5°
7	n-Propyltrichlorosilan	(3-Phenylpropyl)- methyldichlorosilan	3:1	163.7°± 2.3°	14,7°± 1,2°

^{*} depending on the type of glass

Table 1: Contact angles and roll off angles of coatings composed of various silane mixtures on glass.

Example 8

Contact angles of other liquids on MPPS-coated glass slides were determined as described hereinabove (Table 2). All liquids were purchased from Fluka in the highest purity grades available and kept under appropriate atmosphere (air, N2, Ar). Contact angles given in table 2 are advancing angles (sessile drop method). For every contact angle four to six movies of a growing drop (2 μ l to 20 μ l) were automatically evaluated frame by frame by the Dataphysics software and checked manually for consistency afterwards. Irregular (no convergence, large differences in left and right contact angle) data were rejected. The obtained contact angles were averaged per liquid. For large contact angles higher than 150° the software systematically overestimated the contact angles. For thiodiethylene glycol and glycerol the contact angles were determined by hand.

Surface Energy [mN/m]	Contact Angle	
32.7	7° ± 1°	
37.17	22° ± 4°	
44.6	112° ± 2°	
48	148° ± 5°	
53.5	156° ± 5°	
62.7	162° ± 5°	
	32.7 37.17 44.6 48 53.5	

Table 2. Contact angles of several liquids on MPPS-coated glass slides.

Example 9

The preparation of MPPS-coatings on various substrates and contact angle measurements were performed as described hereinabove (Example 1). The contact angles are reported in Table 3.

Substrate	Contact angle		
Cotton fabric	155°-165° *		
Wood	155-165° *		
Cellulose	165°		
Polyethylene	155°		
Aluminium	165°		
Titanium	165°		
Silicium	165°		
Silicon	165°		
Ceramics	155°		

Table 3: Contact angles and roll off angles of MPPS coatings on various substrates

Example 10

Durability of MPPS-coated glass slides:

- a) A sample of Example 1 was exposed in an autoclave at pressures of 1.5 bar and 2.6 bar and temperatures of 125 °C and 140°C, respectively, for up to 9 h. Contact angles measured after the treatment showed no significant deviations from the initial contact angles (Table 4).
- b) A sample of Example 1 was placed in a drying chamber at 250 °C for 24 h. Contact angles measured after the treatment showed no significant deviations from the initial contact angles (Table 4).
- c) A sample of Example 1 was placed in a liquid nitrogen (- 196 °C) for 10 min. Contact angles measured after the treatment showed no significant deviations from the initial contact angles (Table 4).
- d) A sample of Example 1 was exposed to UV radiation (35 Watt, distance sample to source: 10 cm) for 3 h. Contact angles measured after the treatment showed no significant deviations from the initial contact angles (Table 4).
- e) A sample of Example 1 was exposed to various, commercially available detergents for 24 h and subsequently rinsed with water or organic solvents, such as acetone, ethanol or chloroform, and dried. Contact angles measured after the treatment showed no significant deviations from the initial contact angles.

Durability Measurement	Exposure time	contact angle before	contact angle after
a)	9 h	169.1°	169.0°
b)	24 h	165.7° ± 1.9 °	165.1° ± 1.6°

^{*} no exact contact angle measurement possible due to macroscopic surface roughness (see also Figures 7 and 8).

c)	ca. 10 min	166.8° ± 1.6°	165.9° ± 1.9°
d)	3 h	170.3° ± 2.3°	168.8° ± 1.9°

Table 4. Durability measurements of a MPPS-coated glass slide

Claims

1. A composition for coating comprising at least one compound of formula I and at least one compound of formula II

$$R^aSi(R^1)_n(X^1)_{3-n}$$

I

$$R^b \mathrm{Si}(R^2)_m(X^2)_{3\text{-}m}$$

П

wherein

R^a is a straight-chain or branched C₍₁₋₂₄₎ alkyl group,

R^b is an aromatic group, such as an optionally substituted carbocyclic and heterocyclic group comprising five-, six- or ten-membered ring systems, which is linked by a single covalent bond or a spacer unit, such as a straight-chain or branched alkyl residue having 1 to 8 carbon atoms, to the Si- atom,

R¹ and R² are independently of each other a lower alkyl group, such as a straight chain and branched hydrocarbon radical having 1 to 6 carbon atoms,

X¹ and X² are independently of each other a hydrolysable group, such as a halogen or an alkoxy group and

n, m are independently of each other 0 or 1,

with the proviso that if n and m are independently of each other 0 or 1, X may represent the same or different groups.

- 2. A composition according to claim 1, wherein the volume ratio of a compound of formula I to a compound of formula II ranges from 1:100 to 100:1, preferably from 1:50 to 50:1, more preferably from 1:10 to 10:1, most preferably from 1:1 to 5:1.
- 3. A substrate having a coating formed of a composition according to claims 1 or 2.
- 4. A substrate according to claim 3, wherein the coating has a thickness of 1 to 350 nm.
- 5. A substrate according to claim 3, wherein the substrate is natural or artificial and is selected from a fabric, metal, glass, ceramics, cellulose, paper, wood and polymers.

- 6. A method of production of a substrate comprising applying a coating formed of a composition according to claims 1 or 2.
- 7. A textile having a coating formed of a composition according to claims 1 or 2.
- 8. A glass device having a coating formed of a composition according to claims 1 or 2.
- 9. A sanitary device having a coating formed of a composition according to claims 1 or 2.

Abstract

A composition for coating comprising at least one compound of formula I and at least one compound of formula II

$$R^a Si(R^1)_n(X^1)_{3-n}$$

$$R^b Si(R^2)_m(X^2)_{3-m}$$
 II

Ι

wherein

R^a is a straight-chain or branched C₍₁₋₂₄₎ alkyl group,

R^b is an aromatic group, such as an optionally substituted carbocyclic and heterocyclic group comprising five-, six- or ten-membered ring systems, which is linked by a single covalent bond or a spacer unit, such as a straight-chain or branched alkyl residue having 1 to 8 carbon atoms, to the Si- atom,

R¹ and R² are independently of each other a lower alkyl group, such as a straight chain and branched hydrocarbon radical having 1 to 6 carbon atoms,

 X^1 and X^2 are independently of each other a hydrolysable group, such as a halogen or an alkoxy group and

n, m are independently of each other 0 or 1,

with the proviso that if n and m are independently of each other 0 or 1, X may represent the same or different groups.

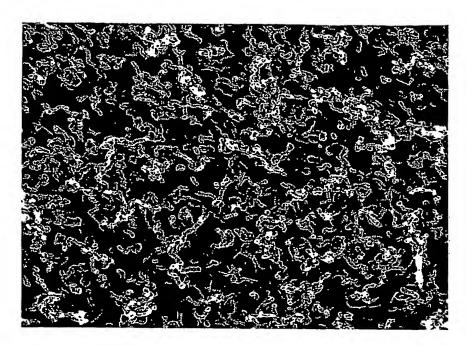


Fig. 1. SEM image of the MPPS coating on a silicon wafer (3.5 μ m by 2.7 μ m). The filaments are up to 1 μ m long and about 40 nm in diameter.

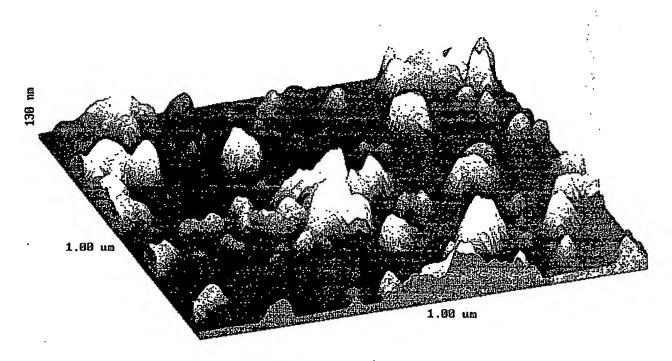


Fig. 2. 3D-presentation of an AFM height image of a MPPS-coated glass slide. The z-scale of 130 nm denotes the height difference from lowest to highest pixel.

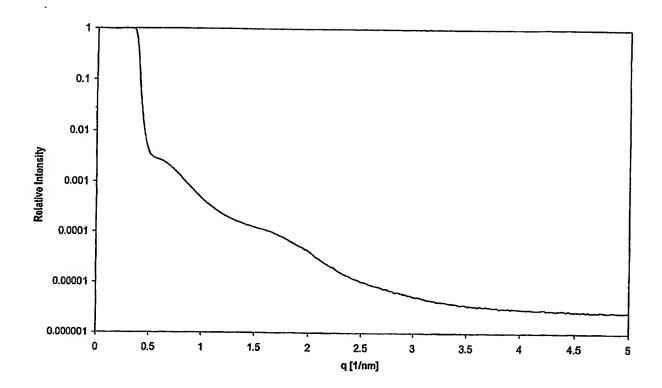


Fig. 3. X-ray reflectivity curve of a MPPS-coated glass slide.

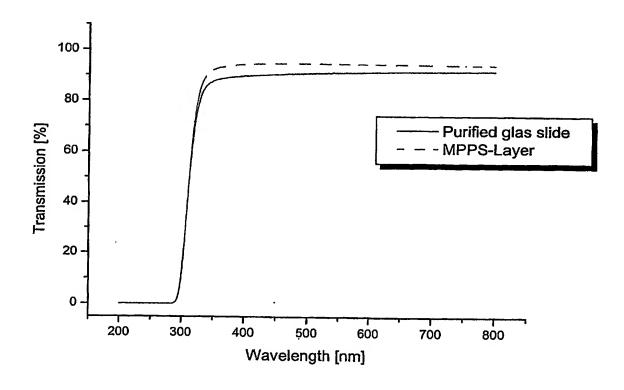


Fig. 4. UV-Vis spectra of a MPPS-coated glass slide compared to a purified glass slide.

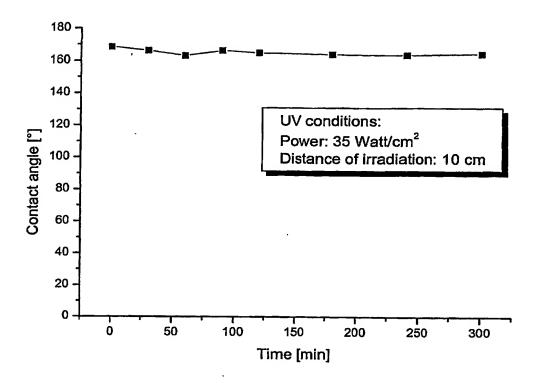


Fig. 5. Durability of a MPPS-coated glass slide subjected to long-term UV-irradiation.

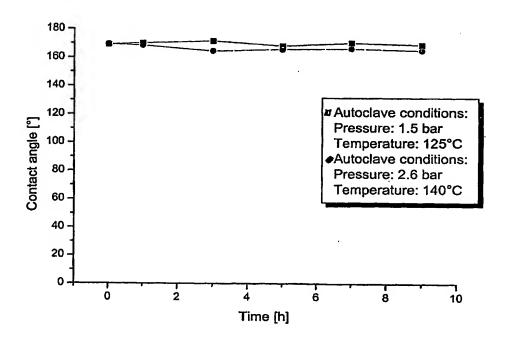


Fig. 6. Durability of a MPPS-coated glass slide subjected water vapour.

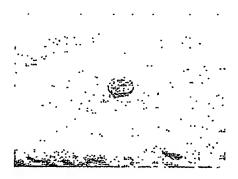


Fig. 7. A 10 μ l water droplet on a coated cotton fabric.

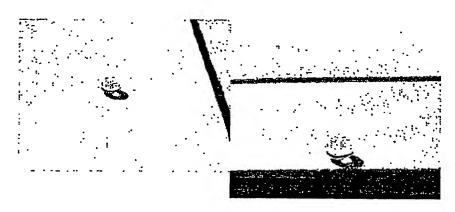


Fig. 8. A $10 \mu I$ water droplet on a wood.

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